Exhibit 1 Declaration of Applicants



PATENT APPLICATION ATTORNEY DOCKET NO. 100201669-1

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

ART UNIT: 2891

EXAMINER: Christian D. Wilson

APPLICANT: Ashton et al.

SERIAL NO.: 10/654189

FILED: September 3, 2003

CONFRM. NO.: 5161

FOR: ULTRA-HIGH DENSITY STORAGE DEVICE USING PHASE CHANGE DIODE MEMORY CELLS AND METHODS OF FABRICATION

THEREOF

RESPONSE/AMENDMENT

CERTIFICATE OF MAILING

DATE OF DEPOSIT: C

I hereby certify that this paper or fee (along with any paper or fee referred to as being attached or enclosed) is being deposited with the United States Postal Service with sufficient postage as first class mail on the date indicated above and is addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-

Vaughn W. North

<u>UNDER 37 C.F.R. § 1.131</u>

Assistant Commissioner of Patent and Trademarks Washington, D.C. 20231

- I, Gary R. Ashton, declare as follows:
- 1. I am a named co-inventor in the above-captioned patent application and of the subject matter described and claimed therein.
- 2. The invention in the above-captioned patent application was conceived and reduced to practice by Gary A. Gibson, Robert N. Bicknell-Tassius and me, collaborating as co-inventors.

- 3. The invention as described and claimed in the above-captioned US patent application No. 10/654189 was reduced to practice in the United States by Gary A. Gibson, Robert N. Bicknell-Tassius, and me prior to May 1, 2003, the effective date of the Chaiken 499 Published Patent Application.
- 4. Exhibit 2, attached hereto, is a redacted copy of run logs showing results of the utilization of the claimed invention. Exhibit 2 discloses run log C1462 and run log C1464, both run under my supervision, in collaboration with Gary A. Gibson and Robert N. Bicknell-Tassius. Both run logs C1462 and C1464 show reduction to practice by disclosing samples having In₂Se₃ on a CIGS substrate. The term "CIGS", as disclosed in the above captioned patent application, refers to CuInSe doped with gallium to form various stoichiometric materials of copper indium gallium selenide including but not limited to (Cu(In,Ga)Se₂) and Cu(In_{1-x}Ga_x)Se₂. The claimed invention having a substrate containing molybdenum is also disclosed on run log 1464.
- 5. The documentation attached with the run logs as part of Exhibit 2, namely the EBIC graph for samples C1462 and 1464, shows the EBIC gain as a function of emitter beam voltage for samples C1462 and C1464. The graph describes the samples as having IN₂Se₃ as the top layer with CIGS as the bottom layer of three of the four described samples.
- 6. The attached EBIC graph confirms that the structure of samples C1462 and C1464 includes CIGS as the bottom layer of the diode device. Accordingly, Exhibit 2 shows that the structure described and claimed in the above-captioned patent application was reduced to practice prior to the effective date of May 1, 2003 of the Chaiken 499 Published Patent Application.

I declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful, false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code, and that such willful, false statement may jeopardize the validity of the application or any patent issuing thereon.

DATED this 28 day of July, 2005.

Gary R. Ashton

BEST AVAILABLE COPY

Exhibit 2 to Declaration of Gary R. Ashton



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IN THE UNITED STATES PATENT & TRADEMARK OFFICE

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EXAMINER: Christian D. Wilson

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Vaughn W. North

DECLARATION OF ROBERT N. BICKNELL-TASSIUS UNDER 37 C.F.R. § 1.131

Assistant Commissioner of Patent and Trademarks Washington, D.C. 20231

- I, Robert N. Bicknell-Tassius, declare as follows:
- 1. I am a named co-inventor in the above-captioned patent application and of the subject matter described and claimed therein.
- 2. The invention in the above-captioned patent application was conceived and reduced to practice by Gary R. Ashton, Gary A. Gibson, and me, collaborating as co-inventors.

- 3. The invention as described and claimed in the above-captioned US patent application No. 10/654189 was reduced to practice in the United States by Gary A. Gibson, Robert N. Bicknell-Tassius, and me prior to May 1, 2003, the effective date of the Chaiken 499 Published Patent Application.
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DATED this 28 day of July, 2005.

Robert M. Bicknell-Tassius

BEST AVAILABLE COPY

Exhibit 2 to Declaration of Robert N. Bicknell-Tassius



PATENT APPLICATION ATTORNEY DOCKET NO. 100201669-1

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

ART UNIT: 2891

EXAMINER: Christian D. Wilson

APPLICANT: Ashton et al.

SERIAL NO.: 10/654189

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CELLS AND METHODS OF FABRICATION

THEREOF

RESPONSE/AMENDMENT

CERTIFICATE OF MAILING UNDER 37 C.F.R. § 1.8

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Vaughn W. North

DECLARATION OF GARY A. GIBSON UNDER 37 C.F.R. § 1.131

Assistant Commissioner of Patent and Trademarks Washington, D.C. 20231

- I, Gary A. Gibson, declare as follows:
- 1. I am a named co-inventor in the above-captioned patent application and of the subject matter described and claimed therein.
- 2. The invention in the above-captioned patent application was conceived and reduced to practice by Gary R. Ashton, Robert N. Bicknell-Tassius, and me, collaborating as co-inventors.

- 3. The invention as described and claimed in the above-captioned US patent application No. 10/654189 was reduced to practice in the United States by Gary A. Gibson, Robert N. Bicknell-Tassius, and me prior to May 1, 2003, the effective date of the Chaiken 499 Published Patent Application.
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DATED this 23% day of July, 2005.

Sary A. Gibson

Page 3 of 3

Exhibit 2 to Declaration of Gary A. Gibson

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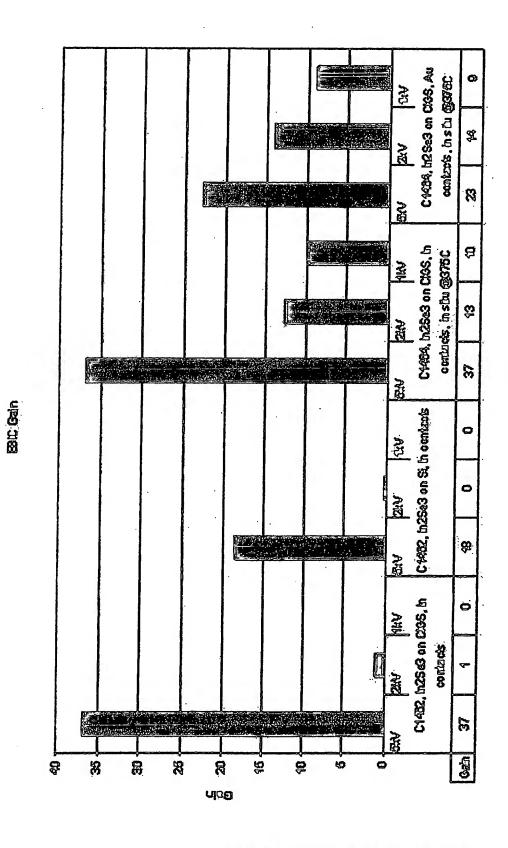
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EBIC data on 4 samples



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